

A1
concl'd
B, 12. (Amended) A method according to Claim 7, wherein the inversion of processing region is based on one of etch-back method, lift-off method, damascene method, and selective deposition method.

A2
B, 16. (Amended) A method according to any one of Claims 4 - 6, wherein the second mask comprises a resist.

A3
B, 31. (Amended) A mold for production of a diffractive optical element, characterized in that the mold is manufactured in accordance with a method as recited in any one of Claims 1 - 4.

B, 32. (Amended) A diffractive optical element characterized in that the diffractive optical element is manufactured in accordance with a method as recited in any one of Claims 1 - 4.

REMARKS

Claims 11, 12, 16, 31 and 32 have been amended to correct improper multiple dependencies. Claim 11 has also been amended for clarification. No new matter has been added.

Favorable consideration of the present case and early passage to issue are respectfully requested.